

SAH  
#2  
10.37.01

INFORMATION DISCLOSURE CITATION			Atty Docket 65321 / 269250		Serial No. <del>Not Yet Assigned</del> 09/941360	
PTO-1449			Applicant: Farhat et al.			
Date Mailed: August 28, 2001			Filing Date August 28, 2001		Group Art Unit 1741	
U.S. PATENT DOCUMENTS						
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
DN	3959089	05/25/76	Watts	1	1	
DN	4610772	09/09/86	Palnik	1	1	
DN	5024735	06/18/91	Kadija	1	1	
DN	6004880	12/21/99	Liu et al	1	1	
DN	3395092	07/30/68	Ribes	1	1	
DN	3436259	04/01/69	Regg et al.	1	1	
DN	3890746	06/24/75	Saegusa et al.	1	1	
DN	5863412	01/26/99	Ichinoise et al.	1	1	
DN	5755859	05/26/98	Brusic et al.	1	1	
DN	5807165	09/15/98	Uzoh et al.	1	1	
DN	5930669	07/27/99	Uzoh	1	1	
DN	5933753	08/03/99	Simon et al.	1	1	
DN	6004880	12/21/99	Liu et al.	1	1	
DN	5171412	12/15/92	Talieh et al.	1	1	
DN	5429733	07/04/95	Ishida	1	1	
DN	5558568	09/24/96	Talieh et al.	1	1	
DN	5650039	07/22/97	Talieh	1	1	
DN	5692947	12-02-97	Talieh et al.	1	1	
DN	5833820	11/10/98	Dubin	1	1	
EXAMINER <i>Donald R Valentine</i>			DATE CONSIDERED <i>6/03</i>			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<b>INFORMATION DISCLOSURE CITATION</b>  PTO-1449  Date Mailed: August 28, 2001				Atty Docket 65321 / 269250		Serial No. Not Yet Assigned	
				Applicant: Farhat et al.			
				Filing Date August 28, 2001		Group Art Unit	
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
RV	DE 2008664	09/09/71	Germany	<del>_____</del>	<del>_____</del>		
RV	DE 4324330	03/02/94	Germany	<del>_____</del>	<del>_____</del>		
RV	EP 0903774 A2	03/24/99	EP	<del>_____</del>	<del>_____</del>		
RV	EP 0960693 A2	12/01/99	EP	<del>_____</del>	<del>_____</del>		
RV	WO 95/00295	01/05/95	PCT	<del>_____</del>	<del>_____</del>		
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
RV	M. Rubinstein, "Tampongalvanisieren in de Praxis, Teil 2." GALVANOTECHNIK, Vol. 79, No. 10, 1988, pp. 3263-3270 <span style="float: right;">No worth</span>						
RV	J.M. Steigerwald, R. Zirpoli, S.P. Murarka, D. Price and R.J. Gutman, "Pattern Geometry Effects in the Chemical-Mechanical Polishing of Inlaid Copper Structures", October 1994, pp. 2842-2848						
RV	Alan C. West, Chin-Chang Cheng and Brett C. Baker, "Pulse Reverse Copper Electrodeposition in High Aspect Ratio Trenches and Vias", September 1998, pp. .070-3073						
RV	Robert C. Contolini, Anthony F. Bernhardt and Steven Mayer, "Electrochemical Planarization for Multilevel Metallization", September 1994, pp. 2503-2510						
RV	C. Madore, M. Matlosz and D. Landolt, "Blocking Inhibitors in Cathodic Leveling", I. Theoretical Analysis", December 1996, pp. 3927-3942						
EXAMINER <i>Donald B. Valentin</i>				DATE CONSIDERED <i>6/03</i>			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.